THE CLAIMS

This listing of claims will replace all prior versions, and listings, of claims in the application.

What is claimed is:

1. (Previously Presented) A system comprising:

a first robotic arm assembly for capturing and releasing a semiconductor wafer, the first robotic arm having at least two degrees of freedom;

a second robotic arm for capturing and releasing an interleaf, the second robotic arm having first and second ends and at least two degrees of freedom;

an end effector attached to the second end of the second robotic arm, the end effector configured to apply positive pressure to a surface of the interleaf facing the end effector for capture and release thereof and having a sensor to detect a proximity and engagement of the interleaf with the end effector, the sensor for determining a reduction in said positive pressure; and

a controller for actuation of the first and second robotic arms, the first and second robotic arms operating substantially simultaneously.

2. (Previously presented) The system according to claim 1 wherein the second robotic arm comprises:

a transfer arm having a first end and a second end, the arm being mounted to a second arm base; and

a counterweight attached to the first end of the transfer arm.

3. (Cancelled)

- 4. (Cancelled)
- 5. (Cancelled)
- 6. (Previously Presented) The system according to claim 1 wherein the sensor uses differential pressure, reflectance, imaging, capacitance, or inductance to detect proximity and engagement of the interleaf.
- 7. (Previously Presented)The system according to claim 1 further comprising a detection sensor to detect the material properties of the interleaf.
- 8. (Previously Presented) The system according to claim 7 wherein the detection sensor uses differential pressure, reflectance, imaging, capacitance, or inducting to detect the material properties of the interleaf.
- 9. (Previously Presented) The system according to claim 1 wherein the end effector arm further comprises electrodes to provide an electrostatic charge for capturing the interleaf.
- 10. (Original) The system according to claim 2 wherein the end effector is slidably disposed in a substantially vertical orientation at the second end of the transfer arm.
- 11. (Original) The system according to claim 10 wherein the end effector is configured to vertically actuate independently of the base.

- 12. (Original) The system according to claim 1 wherein at least one of the robotic arms is pneumatically actuated.
- 13. (Original) The system according to claim 1 wherein at least on of the robotic arms is actuated with electric servo motors.
- 14. (Previously Presented) The system according to claim 1 comprising an interleaf cassette holder including a pneumatic separator for separation of the interleafs, wherein the pneumatic separator co-acts with the end effector to capture the interleaf.
- 15. (Previously Presented) An assembly comprising:

a transfer arm having a first and a second end, the arm being mounted to a second arm base;

a counterweight attached to the first end of the transfer arm;

an end effector attached to a second end of the transfer arm, the end effector configured to apply positive pressure to a surface of the substrate facing the end effector; and

a pneumatic separator for separation of the interleafs, wherein the pneumatic separator is actuated in sequence with the end effector to facilitate capturing of an interleaf.

- 16. (Cancelled)
- 17. (Previously Presented) An assembly according to claim 15 further comprising a detection sensor to detect the material properties of the substrate when coupled to the end effector.

18. – 24. (Withdrawn)

- 25. (Previously presented) The system according to claim 2 wherein the end effector is configured to apply variable pressure forces to capture and release the interleaf.
- 26. (Previously Presented) The system according to claim 1 wherein the end effector is configured to sequentially apply negative and positive pressures to capture and release the interleaf.
- 27. (Previously Presented) The assembly according to claim 15 wherein the end effector is configured to sequentially apply positive and negative pressures to the substrate.